



In re application of: Trung T. Doan

Serial No.: 09/652,969

Filed: August 31, 2000

For: CHEMICAL DISPENSING SYSTEM
FOR SEMICONDUCTOR WAFER
PROCESSING

§ Group Art Unit: 1763
§
§ Examiner: Sylvia R. MacArthur
§
§ Atty. Docket: 93-0421.05
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#7
7/23/01
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Certificate of Mailing (37 C.F.R. § 1.8)

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on the date below:

7-10-01
Date

Irish Donnan-Haid
Signature

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136(a)

Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

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TC 1700

Applicant hereby petitions to extend the period for response to the Office Action mailed January 10, 2001 for three (3) months, from April 10, 2001 to July 10, 2001.

Accordingly, the requisite fee is \$ 890. The Commissioner is requested to charge this fee, and any additional fee which may be required to Micron Technology, Inc. Deposit Account 13-3092, Order No. 93-0421.05. A duplicate copy of this petition is enclosed.

Respectfully submitted,

Date: 7/10/01

Charles B. Brantley, II

Charles B. Brantley, II, Reg. No. 38,086
Micron Technology, Inc.
8000 S. Federal Way
Boise, ID 83716-9632
(208) 368-4557

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